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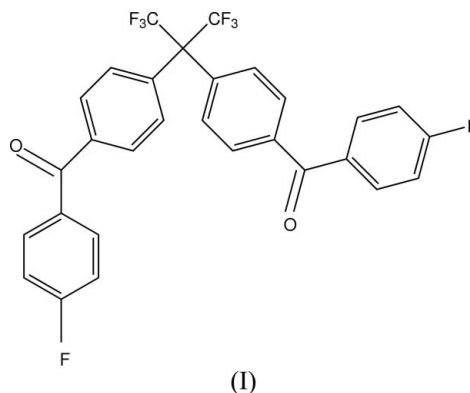
## Key indicators

Single-crystal X-ray study  
 $T = 298$  K  
Mean  $\sigma(\text{C}-\text{C}) = 0.005$  Å  
 $R$  factor = 0.056  
 $wR$  factor = 0.161  
Data-to-parameter ratio = 12.5For details of how these key indicators were automatically derived from the article, see <http://journals.iucr.org/e>.

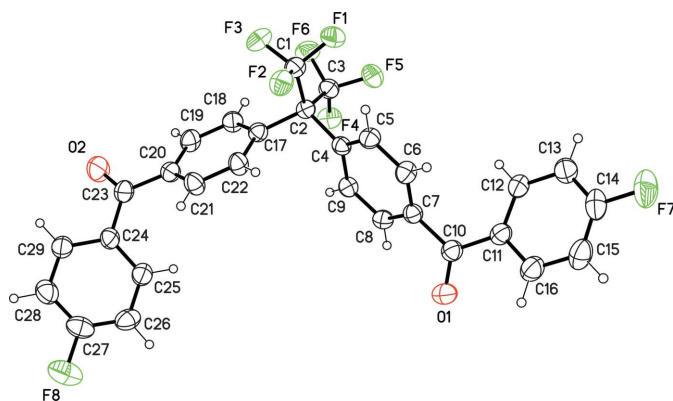
## 4-Fluorophenyl 4-{1,1,1,3,3,3-hexafluoro-2-[4-(4-fluorobenzoyl)phenyl]-2-propyl}-phenyl ketone

In the title compound,  $\text{C}_{29}\text{H}_{16}\text{F}_8\text{O}_2$ , in spite of the symmetric substitution at the hexafluoropropane group, an unsymmetrical conformation is obtained for the fluorobenzoyl substituents. One substituent is oriented *syn* and the other *anti* to the central group.Received 1 June 2006  
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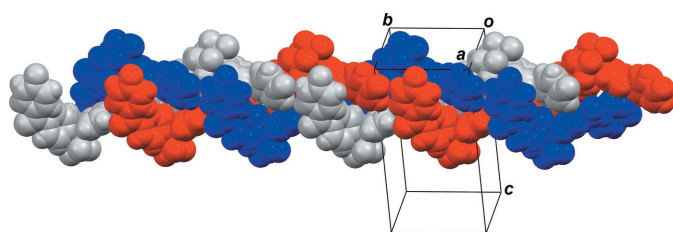
## Comment

As a part of our ongoing studies of poly(phenylene ether ketones) and hexafluoroisopropylidene-containing polymers (Cassidy *et al.*, 1989; Tullos *et al.*, 1990, 1991; Kane *et al.*, 1991; Bruma *et al.*, 1996), aiming at a systematic design of low dielectric polymers that could be used in the electronics industry, we report here the structure of the title compound,  $\text{C}_{29}\text{H}_{16}\text{F}_8\text{O}_2$ , (I).

In the title compound (Fig. 1) the dihedral angle between the least-squares planes of the benzene rings bonded to the central C2 atom is  $79.16(12)^\circ$ , a larger value than that obtained in the precursor of (I), with a corresponding angle of  $66.31(15)^\circ$  (Rodríguez de Barbarín *et al.*, 2006). The  $\text{CF}_3$  groups adopt an eclipsed conformation in both compounds. In the title compound, the (4-fluorobenzoyl) substituents of both benzene rings have dihedral angles of  $50.87(15)^\circ$  (planes C4–C9 and C11–C16) and  $54.80(12)^\circ$  (planes C17–C22 and C24–C29), respectively. In spite of the symmetric substitution at C2, an unsymmetrical conformation is obtained for the fluorobenzoyl groups: one is oriented *syn* and the other *anti* relative to the  $\text{C}(\text{CF}_3)_2$  central core. The conformation of (I) is reflected in the packing, based on a triple-helix supramolecular arrangement (Fig. 2). The polymeric material, if retaining the structural characteristics described above for (I), would support a higher dielectric strain, which might explain the low dielectric constant observed for the corresponding poly(phenylene ether ketone) polymer (Tullos *et al.*, 1991; St Clair *et al.*, 1994).



**Figure 1**  
Molecular structure of (I). Displacement ellipsoids are drawn at the 30% probability level for non-H atoms.



**Figure 2**  
Part of the packing of (I) in a CPK space-filling representation, showing the supramolecular arrangement of the molecules along [010]. Each strand of the triple-helix framework is represented with a different colour.

## Experimental

Compound (I) and its precursor were synthesized following the procedure outlined by St Clair *et al.* (1994). Single crystals for both compounds were obtained by slow evaporation of a methanol solution at 298 K.

### Crystal data

$C_{29}H_{16}F_8O_2$   
 $M_r = 548.42$   
 Monoclinic,  $P2_1/n$   
 $a = 9.940$  (2) Å  
 $b = 11.202$  (5) Å  
 $c = 21.710$  (9) Å  
 $\beta = 90.68$  (4)°  
 $V = 2417.2$  (16) Å<sup>3</sup>

$Z = 4$   
 $D_x = 1.507$  Mg m<sup>-3</sup>  
 Mo  $K\alpha$  radiation  
 $\mu = 0.14$  mm<sup>-1</sup>  
 $T = 298$  (1) K  
 Prism, colourless  
 $0.60 \times 0.16 \times 0.04$  mm

### Data collection

Bruker *P4* diffractometer  
 $\omega$  scans  
 5765 measured reflections  
 4396 independent reflections  
 2319 reflections with  $I > 2\sigma(I)$

$R_{int} = 0.023$   
 $\theta_{max} = 25.4^\circ$   
 3 standard reflections  
 every 97 reflections  
 intensity decay: <1%

### Refinement

Refinement on  $F^2$   
 $R[F^2 > 2\sigma(F^2)] = 0.056$   
 $wR(F^2) = 0.161$   
 $S = 1.03$   
 4396 reflections  
 353 parameters  
 H-atom parameters constrained

$w = 1/[\sigma^2(F_o^2) + (0.0533P)^2 + 1.9495P]$   
 where  $P = (F_o^2 + 2F_c^2)/3$   
 $(\Delta/\sigma)_{max} < 0.001$   
 $\Delta\rho_{max} = 0.25$  e Å<sup>-3</sup>  
 $\Delta\rho_{min} = -0.20$  e Å<sup>-3</sup>  
 Extinction correction: *SHELXTL-Plus*  
 Extinction coefficient: 0.0072 (10)

H atoms were placed in idealized positions ( $C-H = 0.93$  Å) and constrained to ride on their parent atoms, with  $U_{iso}(H) = 1.2 U_{eq}(C)$ .

Data collection: *XSCANS* (Siemens, 1996); cell refinement: *XSCANS*; data reduction: *XSCANS*; program(s) used to solve structure: *SHELXTL-Plus* (Sheldrick, 1997); program(s) used to refine structure: *SHELXTL-Plus*; molecular graphics: *SHELXTL-Plus* and *MERCURY* (Version 1.4.1; Bruno *et al.*, 2002); software used to prepare material for publication: *SHELXTL-Plus*.

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